## IN THE SPECIFICATION:

On page 1, before line 1, please add the following new paragraph:

-- Cross Reference to Related Application

This application is a divisional of U.S. Application Serial No. 09/830,380, filed April 25, 2001. --

Please amend the sub-paragraph beginning on page 14, line 15, as follows:

figure Figure 3 between a layer of hafnium oxide comprising crystals of hafnium oxide resulting from ion bombardment of the substrate and an amorphous layer according to the invention.

Please amend the sub-paragraph beginning on page 14, line 23, as follows:

Figure 5 is a curve representing the reflection of a mirror component of figure Figure 4 in function of wavelength.

Please amend the paragraph beginning on page 15, line 15, as follows:

Such plots plots are shown in figures Figures 2 and 3.

Please amend the paragraph beginning on page 16, line 1, as follows:

On the other hand, <u>layers curves</u> 8, 9, 10 and 12 reveal diffraction peaks 13 characteristic of crystalline materials.

Please amend the paragraph beginning on page 16, line 12, as follows:

A first embodiment example relates to the production of a mirror 4 at 1064 nm. The emponent mirror 4 must ensure a reflecting function at 1064 nm under an angle of incidence of 45°. This mirror 4 is produced by a stack of formula 12 (HB) H2B where H represents a mono-layer of thickness 156 nm of HfO<sub>2</sub> and B a mono-layer of 213 nm of SiO<sub>2</sub>.

Please amend the paragraph beginning on page 16, line 19, as follows:

## HAYES SOLOWAY P.C.

130 W. CUSHING ST. TUCSON, AZ 85701 TEL. 520.882.7623 FAX, 520.882.7643

175 CANAL STREET MANCHESTER, NH 03101 TEL. 603.668.1400 FAX, 603.668.8567

Docket No. BREV 13186 DIV Preliminary Amendment

A cross-section of this optical component mirror 4 intended to represent the stacking of the layers is shown in figure Figure 4. On a substrate 1, the mirror according to the invention comprises first of all a stack of twelve layers H of amorphous hafnium oxide 2, each alternating with a layer B of silicon oxide 3. It then comprises two layers H of amorphous hafnium oxide 2 and finally a layer B of silicon oxide 3.

Please amend the paragraph beginning on page 18, line 15, as follows:

In [figure] Figure 6, the optical component 6 is shown, with the aim of simplification, with a single example of the two-layer composition comprising a layer of amorphous hafnia 2 alternating with a layer of silicon oxide 3.

Please amend the paragraph beginning on page 18, line 20, as follows:

The curve in figure Figure 7 shows the optical performance of component 6 in terms of percentage of light transmission in the working spectral range expressed in nm. It can be seen that the percentage is very close to 100% within the entire working range. The behaviour of this component under laser flux is shown to be excellent within the utilisation wavelength range.

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175 CANAL STREET MANCHESTER, NH 03101 TEL. 603.668.1400 FAX. 603.668.8567

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